## IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A silver alloy comprising a composition containing at least four elements including Ag (silver) as its major component, 0.10 to 2.89 wt% of Pd (palladium), 0.10 to 2.89 wt% of Cu (copper) and 0.01 to 1.50 wt% of Ge (germanium), and wherein the total amount of Pd, Cu and Ge is 0.21 to 3.00 wt%.

Claim 2 (Currently Amended): The silver alloy according to Claim 1, wherein the silver alloy consists of Ag, Pd, Cu and Ge having a composition excluding any component other than the four elements and wherein the content of the Ag in the alloy is 97.00 to 99.79 wt%.

Claim 3 (Currently Amended): The silver alloy according to Claim 1 or 2, wherein the ratio of the content of Cu to the content of Ge, namely, Cu content/Ge content, is 1/20 (1/20) to (20/1) 20/1.

Claim 4 (Currently Amended): The silver alloy according to Claim 1 or 2, wherein the silver alloy, after being heat-treated at 250°C, for one hour, in air, having has a reflectance of 90% or more for light having a wavelength of 550 nm after heat treated at 250°C for one hour in air.

Claim 5 (Currently Amended): The silver alloy according to Claim 3, wherein the silver alloy, after being heat-treated at 250°C, for one hour, in air, having has a reflectance of 90% or more for light having a wavelength of 550 nm after heat-treated at 250°C for one hour in the air.

Claim 6 (Currently Amended): The silver alloy according to Claim 1 or 2, wherein the silver alloy, after exposure to a 100 ppm hydrogen sulfide atmosphere, at ambient temperature, for 48 hours, having has a reflectance of 75% or more for light having a wavelength of 550 nm after exposed to a 100 ppm hydrogen sulfide atmosphere at ambient temperature for 48 hours.

Claim 7 (Currently Amended): The silver alloy according to Claim 3, wherein the silver alloy, after exposure to a 100 ppm hydrogen sulfide atmosphere, at ambient temperature, for 48 hours, has having a reflectance of 75% or more for light having a wavelength of 550 nm after exposed to a 100 ppm hydrogen sulfide atmosphere at ambient temperature for 48 hours.

Claim 8 (Currently Amended): The silver alloy according to Claim 1 or 2, wherein the silver alloy, after exposure to a high temperature and high humidity atmosphere of 85°C and 90 RH%, for 200 hours, has having a reflectance of 88% or more for light having a wavelength of 550 nm after exposed to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours.

Claim 9 (Currently Amended): The silver alloy according to Claim 3, wherein the silver alloy, after exposure to a high temperature and high humidity atmosphere of 85°C and 90 RH%, for 200 hours, has having a reflectance of 88% or more for light having a wavelength of 550 nm after exposed to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours.

Claim 10 (Currently Amended): The silver alloy of Claim 1, wherein the silver alloy is in the form of a sputtering target sputtering target material formed of the silver alloy as claimed in Claim 1, 2, 3, 4, 5, 6, 7, 8 or 9.

Claim 11 (Currently Amended): The silver alloy of Claim 1, wherein the silver alloy is in the form of a thin film thin film formed of the silver alloy as claimed in Claim 1, 2, 3, 4, 5, 6, 7, 8 or 9.

Claim 12 (Currently Amended): The silver alloy thin film according to Claim 11, wherein the silver alloy thin film, after heat-treatment at 250°C, for one hour, in air, has having a reflectance of 90% or more for light having a wavelength of 550 nm after heat-treated at 250°C for one hour in the air.

Claim 13 (Currently Amended): The silver alloy thin film according to Claim 11, wherein the silver alloy thin film, after exposure to a 100 ppm hydrogen sulfide atmosphere, at ambient temperature, for 48 hours, has having a reflectance of 75% or more for light having a wavelength of 550 nm after exposed to a 100 ppm hydrogen sulfide atmosphere at ambient temperature for 48 hours.

Claim 14 (Currently Amended): The silver alloy thin film according to Claim 11, wherein the silver alloy thin film, after exposure to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours, has having a reflectance of 88% or more for light having a wavelength of 550 nm after exposed to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours.

Claim 15 (Currently Amended): The silver alloy thin film according to Claim 11, 12, 13 or 14, wherein the said silver alloy thin film being is a reflecting film.

Claim 16 (Currently Amended): The silver alloy thin film according to Claim 11, 12, 13 or 14, said silver alloy wherein the thin film being is a thin type semi-transmissive film.

Claim 17 (Currently Amended): The silver alloy thin film according to Claim 11, 12, 13 or 14, said silver alloy wherein the thin film being is a patterned electrode or wiring.

Claim 18 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film in the form of a self-emitting type display A self-emitting type display comprising the reflecting film as claimed in Claim 15 or a perforated semi-transmissive film obtained by forming light transmissive holes that transmit a part of incident light in the reflecting film as claimed in Claim 15.

Claim 19 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film is in the form of a flat panel display A flat panel display comprising the reflecting film as claimed in Claim 15 or a perforated semi-transmissive film obtained by forming light transmissive holes that transmit a part of incident light in the reflecting film as claimed in Claim 15.

Claim 20 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film is in the form of an electrode A reflecting electrode comprising the reflecting film as claimed in Claim 15 or a perforated semi-transmissive film obtained by forming light

transmissive holes that transmit a part of incident light in the reflecting film as claimed in Claim 15.

Claim 21 (Currently Amended): The reflecting film of Claim 11, wherein the reflecting film is in the form of an electronic part Electronic parts comprising using the silver alloy thin film as claimed in Claim 11, 12, 13, 14, 15, 16 or 17.

Claim 22 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film is in the form of an optical disk An optical disk medium comprising at least one of the reflecting film as claimed in Claim 15 and the thin type semi-transmissive film as claimed in Claim 16.

Claim 23 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film is in the form of a light part Light parts comprising the reflecting film as elaimed in Claim 15.

Claim 24 (Currently Amended): A silver alloy thin The reflecting film according to Claim 15, wherein said silver alloy thin the reflecting film is an electromagnetic shielding film.

Claim 25 (Currently Amended): The silver alloy of Claim 1, wherein the silver alloy is in the form of a silver alloy paste A silver alloy paste, material formed of the silver alloy as elaimed in Claim 1, 2, 3, 4, 5, 6, 7, 8 or 9.